

OCTANEOPENTYLCYCLOTETRASILANE. SYNTHESIS AND UNUSUAL PROPERTIES

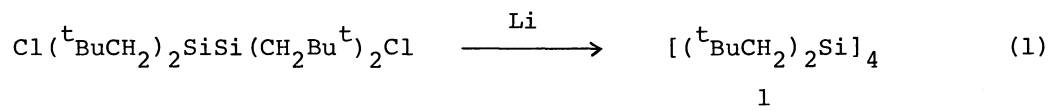
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The entitled compound was synthesized and its molecular structure was determined by X-ray crystallography. Its unusual properties include the lowest energy CT band with TCNE yet observed for cyclotetrasilanes and the easiness of the decomposition of the Si₄ framework on electron-impact fragmentation and thermolysis.

Recently, preparation of the first peralkylcyclotrisilane, hexaneopentylcyclotrisilane, by the reaction of dichlorodineopentylsilane with lithium has been reported from our laboratories.¹⁾ In connection with this compound, we have studied the reaction of 1,2-dichlorotetraneopentylidisilane with lithium and found that the reaction unexpectedly afforded octaneopentylcyclotetrasilane (1) in a good yield (Eg. 1). Here we report the synthesis, structure, and properties of this partic-



ular cyclotetrasilane which differs discernibly in both structure and properties from other cyclotetrasilanes.²⁾

A solution of the dichlorotetraneopentylidisilane (9.0 g, 22 mmol) in DME was treated with lithium (30% dispersion, 1.2 g, 55 mg-atom) at room temperature for 7 h under argon. Work-up and recrystallization from ethanol afforded an analytically pure sample of 1 (3.5 g, 43% yield) as colorless crystals (monoclinic): Mp 264-290 °C (partially decomposed); ¹H NMR (CDCl₃) δ 1.09 (s, 72H) and 1.39 ppm (s, 16H); ¹³C NMR (CDCl₃) δ 31.80 (t and s, CH₂ and CMe₃) and 34.03 ppm (q, CH₃); ²⁹Si NMR (C₆D₆) δ -23.56 ppm; UV (c-hexane) λ_{max} 286 nm (ε 440); Anal. Found: C, 70.50; H, 13.02 %. Calcd for C₄₀H₈₈Si₄: C, 70.31; H, 12.99 %.

An X-ray analysis of 1 (Fig. 1) reveals a value of 2.409 Å (average) for the Si-Si bond length which is the largest among the values yet observed for cyclotetrasilanes^{3,4)} and even larger than that of the cyclotrisilane [(^tBuCH₂)₂Si]₃.⁴⁾ Further, the Si₄ framework assumes a highly folded structure with a dihedral angle of 38.8°, which compares with those in (^tBuMeSi)₄ (36.8°)³⁾ and (ⁱPr₂Si)₄ (37.1°).⁵⁾

Its unusual properties are as follows: (1) 1 shows CT band with TCNE at 600 nm (in CH₂Cl₂) which is the lowest energy transition yet observed for cyclotetrasilanes [e.g., 510 nm in (^tBuMeSi)₄⁶⁾ and 510 nm in (ⁱPr₂Si)₄⁷⁾]. (2) 1 fragments under

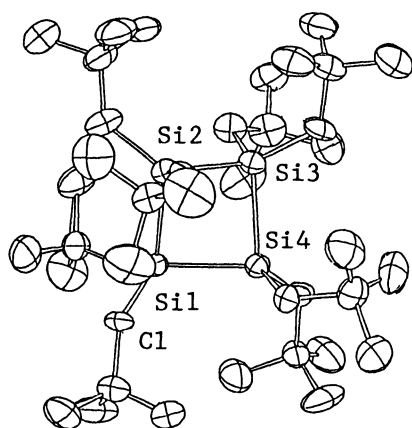
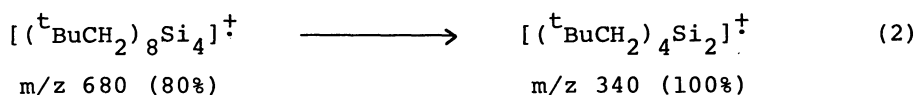


Fig. 1. A Perspective Drawing for 1.
Principal bond lengths (Å) and bond angles (deg): Si(1)-Si(2) 2.433, Si(2)-Si(3) 2.403, Si(3)-Si(4) 2.401, Si(4)-Si(1) 2.398, Si(1)-C(1) 1.91; Si(1)Si(2)Si(3) 86.3, Si(2)Si(3)Si(4) 86.9, Si(3)Si(4)Si(1) 87.1, Si(4)Si(1)Si(2) 86.3.

electron-impact mass spectroscopic conditions (30 eV) in a manner consistent with the formation of tetraneopentyldisilene. 1 gives a peak with m/z 340 (corresponding to the disilene) as the base peak (Fig. 2). The fragmentation of this type



is not observed for peralkylcyclotetrasilanes such as $(^i\text{Pr}_2\text{Si})_4$ and $(^t\text{BuMeSi})_4$, in which the Si_4 units remain intact until most of the alkyl groups on silicon are eliminated.⁷⁾ (3) 1 is much less thermally stable compared to $(^i\text{Pr}_2\text{Si})_4$. For instance, heating a solution of 1 in decalin at 250°C for 24 h in a sealed tube led to 68% decomposition with the formation of 1,2-dihydrotetraneopentyldisilane (4%), while the perisopropyl derivative remained intact under nearly the same conditions.

Comparison of $[(^t\text{BuCH}_2)_2\text{Si}]_4$ with $[(^t\text{BuCH}_2)_2\text{Si}]_3$ is of interest and a work along this line is now underway.

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References

- 1) H. Watanabe, T. Okawa, M. Kato, and Y. Nagai, J. Chem. Soc., Chem. Commun., 1983, 781.
- 2) Presented in part at the VIIth International Symposium on Organosilicon Chemistry, September 9-14, 1984, Kyoto, 4T09.
- 3) C. J. Hurt, J. C. Calabrese, and R. West, J. Organomet. Chem., 91, 273 (1975).
- 4) H. Watanabe, M. Kato, T. Okawa, Y. Nagai, and M. Goto, J. Organomet. Chem., 271, 225 (1984)
- 5) H. Watanabe, M. Kato, T. Okawa, K. Kougo, Y. Nagai, and M. Goto, unpublished work.
- 6) M. Biernbaum and R. West, J. Organomet. Chem., 131, 179 (1977).
- 7) H. Watanabe, T. Muraoka, M. Kageyama, K. Yoshizumi, and Y. Nagai, Organometallics, 3, 141 (1984).

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